

UNITED STATES PATENT AND TRADEMARK OFFICE

BEFORE THE PATENT TRIAL AND APPEAL BOARD

~~MICRON TECHNOLOGY, INC.,
INTEL CORPORATION, AND
GLOBALFOUNDRIES U.S., INC.,~~

~~Petitioners~~

~~v.~~

~~DANIEL L. FLAMM,~~

~~Patent Owner~~

~~Case IPR No. Unassigned~~

~~U.S. Patent No. 6,017,221~~

~~Issued: January 25, 2000~~

~~Named Inventor: _____~~

~~SAMSUNG ELECTRONICS COMPANY, LTD.~~

~~Petitioner~~

~~v.~~

DANIEL L. FLAMM
Patent Owner

Patent No. 6,017,221

~~Daniel L. Flamm~~

~~Title: PROCESS DEPENDING ON PLASMA DISCHARGES SUSTAINED BY
INDUCTIVE COUPLING~~

**PETITION FOR *INTER PARTES* REVIEW
OF U.S. PATENT NO. 6,017,221
~~UNDER 35 U.S.C. §§ 311-319 AND 37 C.F.R. §§ 42.1-.80, 42.100-.123~~**

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TABLE OF CONTENTS

	Page
I. INTRODUCTION	1
II. REQUIREMENTS FOR PETITION FOR INTER PARTES REVIEW	1
A. Grounds for Standing (37 C.F.R. § 42.104(a))	1
B. Notice of Real Party In Interest (37 C.F.R. § 42.8(b)(1))	2
C. Notice of Related Matters (37 C.F.R. § 42.8(b)(2)).....	2
D. Designation of Lead and Back-up Counsel (37 C.F.R. § 42.8(b)(3)) and Service Information (37 C.F.R. § 42.8(b)(4)).....	3
E. Payment of Fees (37 C.F.R. § 42.103).....	4
F. Proof of Service.....	4
III. IDENTIFICATION OF CLAIMS BEING CHALLENGED.....	5
A. Specific Art and Statutory Grounds on Which the Challenges to the Claims are Based.....	5
IV. OVERVIEW OF THE 221 PATENT.....	6
A. The 221 Patent Disclosure.....	7
1. Inductively Coupled Plasma Source.....	7
2. Capacitively Coupled Currents	7
3. Phase and Anti-Phase Portions of the Capacitively Coupled Currents	7
4. Wave Adjustment Circuit	10
V. PERSON HAVING ORDINARY SKILL IN THE ART	12
VI. CLAIM CONSTRUCTION	12
A. “selectively balanced”.....	12
1. Correct Construction: “selectively balanced” means “chosen to be made substantially equally distributed”.....	13
2. Flamm’s Construction: “selectively balanced covers a range, per one’s selection, between 100% balanced to various lesser percentages”.....	15
VII. SUMMARY OF PRIOR ART REFERENCES	16

Petition for *Inter Partes* Review of U.S. Pat. No. 6,017,221

A. Lieberman.....	16
B. Dible.....	17
C. Qian.....	18
D. Hanawa.....	19
E. Collins.....	20
VII. THERE IS A REASONABLE LIKELIHOOD THAT AT LEAST ONE CLAIM OF THE 221 PATENT IS UNPATENTABLE	20
A. Ground 1: Claims 1 and 5-7 Are Rendered Obvious by Lieberman Under 35 U.S.C. § 103(a)	21
1. Lieberman: Claim 1	21
 a) [1.P] A process for fabricating a product using a plasma source.....	21
 b) [1.1] subjecting a substrate to entities, at least one of said entities emanating from a gaseous discharge excited by a high frequency field from an inductive coupling structure.....	21
 c) [1.2] in which a phase portion and an anti-phase portion of capacitive currents coupled from the inductive coupling structure are selectively balanced	22
 d) [1.3] wherein said inductive coupling structure is adjusted using a wave adjustment circuit, said wave adjustment circuit adjusting the phase portion and the anti-phase portion of the capacitively coupled currents	27
2. Lieberman discloses all limitations of dependent claims 5-7.....	28
 a) Claim 5: The process of claim 1 wherein said process is provided in a chamber.....	28
 b) Claim 6: The process of claim 5 wherein the chamber is provided for a process selected from etching, deposition, sputtering, or implantation	29

Petition for *Inter Partes* Review of U.S. Pat. No. 6,017,221

~~c) Claim 7: The process of claim 1 wherein said inductive coupling structure provides a wave multiple selected from a one sixteenth wave, a one eighth wave, a quarter wave, a half wave, a three quarter wave, and a full wave30~~

~~B. Ground 2: Claims 1 and 5-7 Are Rendered Obvious by Lieberman In View of Dible Under 35 U.S.C. § 103(a).....30~~

~~1. Lieberman in view of Dible: Claim 131~~

~~a) [1.P] A process for fabricating a product using a plasma source.....31~~

~~b) [1.1] subjecting a substrate to entities, at least one of said entities emanating from a gaseous discharge excited by a high frequency field from an inductive coupling structure.....31~~

~~c) [1.2] in which a phase portion and an anti phase portion of capacitive currents coupled from the inductive coupling structure are selectively balanced31~~

~~d) [1.3] wherein said inductive coupling structure is adjusted using a wave adjustment circuit, said wave adjustment circuit adjusting the phase portion and the anti phase portion of the capacitively coupled currents33~~

~~2. Lieberman in view of Dible discloses all limitations of dependent claims 5-733~~

~~a) Claim 5: The process of claim 1 wherein said process is provided in a chamber.....33~~

~~b) Claim 6: wherein the chamber is provided for a process selected from etching, deposition, sputtering, or implantation.....34~~

~~c) Claim 7: wherein said inductive coupling structure provides a wave multiple selected from a one sixteenth wave, a one eighth wave, a quarter~~

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